٠.	•				Docket Number (Optional) OKI.631		Application Number NEW		
INFORMATION DISCLOSURE CITATION (Use several sheets if necessary)					Applicant(s) Noriyuki MIURA				
					Filing Date		Group Art Unit		
					December 9, 2003		To Be Assigned		
U.S. PATENT DOCUMENTS									
*EXAMINER INITIAL	REF	DOCUMENT NUMBER	DATE	' NAME"		CLASS	SUBCLASS	FILING DATE IF APPROPRIATE	
1.4.	A	6,093,592	07/25/2000	NAKABAYASHI et al.		438	221		_
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*				FOREIG	PATENT DOCUMENTS				
	REF	DOCUMENT NUMBER	DATE		COUNTRY	CLASS	SUBCLASS	Transla YES	NO NO
1.7.	В	63-313865	65 12/21/1988 JAPAN					Abstract	
1.4.	С	07-211902 08/11/1995 J		JAPAN	JAPAN			Atstract	
1.9.	D	08-051198	02/20/1996	JAPAN		· }	}	AKSTroct	
19.	Ε	2001-135821	05/18/2001	JAPAN			1.}	Abstract	
OTHER DOCUMENTS (Including Author, Title, Date, Pertinent Pages, Etc.)									
Lisa T. Su et al., "OPTIMIZATION OF SERIES RESISTANCE IN SUB-0.2 µm SOI MOSFETs", 1993 IEEE, pgs. 723-726.									
Neal Kistler et al., "SCALING BEHAVIOR OF SUB-MICRON MOSFETS ON FULLY DEPLETED SOI", Solid-State Electronics Vol. 39, No. 4, 1996, pgs. 445-454.									
EXAMINE	R		L all		DATE CONSIDERED	12/	9/01	7	
EXAMINER: Initial if citation considered, whether or not citation is in conformance with MPEP Section 609; Draw line through citation if not in conformance and not considered. Include cony of this form with next communication to applicant.									

Form PTO-A820 (also form PTO-1449)